

**University of Alberta**  
**Department of Chemical and Materials Engineering**

**Lecturer: Dr. Stojan Djokić**

**MAT E 201**  
**Materials Science I**

Assignment No.1 **(13 marks)**  
Due Date: January 17, 2020, by 3:00 pm

1. Define the following terms: (a) composition, (b) structure, (c) synthesis, (d) processing, and (e) microstructure. **(1 mark)**
2. Explain the difference between the terms materials science and materials engineering. **(0.5 marks)**
3. What is the difference between the microstructure and the macrostructure of a material? **(2 marks)**
4. Determine the mass in grams and thickness in  $\mu\text{m}$  of bismuth film which contains  $2.5 \times 10^{21}$  atoms. Consider that the Bi film is rectangular and that its surface area is  $50 \text{ cm}^2$ . Density of Bi is  $9.808 \text{ g/cm}^3$  and its relative atomic mass is  $208.98 \text{ g/mol}$ . **(2 marks)**
5. Density of indium is  $7.286 \text{ g/cm}^3$ , and its atomic relative mass is  $114.82 \text{ g/mol}$ . Density of aluminum is  $2.699 \text{ g/cm}^3$  and its relative atomic mass is  $26.981 \text{ g/mol}$ . Calculate the number of atoms per cubic centimetre for a) In and b) Al. Which element In or Al contains more atoms per cubic centimetre? **(3 marks)**
6. An electronic circuit pattern with the total surface area of  $3 \text{ cm}^2$ , should be coated with  $2 \mu\text{m}$  thick tungsten film. Calculate: a) how many atoms of W are required? b) how many moles of W are required? ( $A_r(\text{W}) = 183.85 \text{ g/mol}$ ,  $\rho(\text{W}) = 19.254 \text{ g/cm}^3$ ). **(3 marks)**
7. Suppose an element has a valence of 2 and an atomic number of 27. Based only on quantum numbers, how many electrons must be present in the 3d energy level? **(0.5 marks)**
8. Calculate the fraction of bonding of  $\text{Sb}_2\text{S}_3$  that is ionic, if the electronegativity of antimony is 2 and the electronegativity of sulphur is 2.5. **(1 mark)**